

Analog Circuits
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Module - 03

Lecture – 02

We now know that the I_D , V_{DS} characteristics of a MOS transistor or the port two characteristics of the MOS transistor are not exactly flat in the saturation region. So, they have a slight upward slope, a current does increase slightly with increasing V_{DS} .

In terms of the expression for the current, we have its additional factor one plus λV_{DS} . What we need to do now is to find out the effect of this on the small signal model. So, this small signal model so far as we know consists of just the g_m . So, this is the gate, this is the drain, and this is the source; this is V_{GS} , and this is $g_m V_{GS}$, and this is the incremental V_{DS} . This by the way is the small signal incremental model. And the symbol for the MOS transistor itself is like that. Now, this g_m is nothing, but the partial derivative of I_D with respect to V_{GS} . And if I calculate that I get $\mu_n C_{ox} W$ by $L V_{GS} - V_T$ times one plus λV_{DS} , so this one plus λV_{DS} appears in this expression as well.

More importantly earlier, the conductance that we call y_{22} that is the conductance that appears across the terminals of port two, in case of a MOS transistor, we know that it is called g_{ds} the drain to source conductance. The partial derivative of I_D with respect to V_{DS} , this we have thought was zero that is basically that is the slope of this curve, the slope of the red curve here is zero, but we now know that it is really the purple curve, so the slope is not zero. So, this is not really the case. And if we calculate that from this expression, you will easily see that it is equal to $\lambda \mu_n C_{ox} W$ by $L V_{GS} - V_T$ square. In fact, the biggest qualitative change appears in this g_{ds} ; g_{ds} was originally zero. There was no conductance here, now we have a conductance g_{ds} given by this expression.

The value of g_m is also modified by some number. Earlier, we were calculating this; now we have this additional modifier. Now, this is not a big change, as I said this λ

V_{DS} is expected to be small compared to one. So, the value of g_m changes a little bit, but we do not usually worry about that. Whereas, this one it was zero, and now have a non-zero conductance. So, this is the most important effect. So, we have a non-zero, drain to source conductance, and of course, this applies to the incremental picture. We have a non-zero drain to source incremental conductance.

So, what do we do in practice, the expression for the current in saturation is $\mu_n C_{ox} W/L (V_{GS} - V_T)^2 (1 + \lambda V_{DS})$. The expression for g_m is $\mu_n C_{ox} W/L (V_{GS} - V_T)$, and the expression for g_{ds} is $\lambda (V_{GS} - V_T)^2$. So, everything changes and these things are now little more cumbersome, because you have a non-linear function, and you also have this additional variable. So, usually what is done is for operating point calculations, this is ignored. So, we just do not even worry about it, when we want to find the drain current, we base it only on the gate to source voltage. This is inaccurate, but again like I said earlier, the goal is to understand the phenomena, not to make the calculation to the last decimal point, because even if you include this, this itself is not accurate. The actual model of the MOSFET is really, really complicated.

So, to get some insight into the operation, this is good enough. So, for operating point calculation most often we just use this. And if we do have to use that one, we actually use incremental calculations to find the effect of this one. We calculate the approximate operating point only using this part of the expression and any effect of this we add in later so that is what we normally do. And similarly, for g_m also, this is ignored, because again we will operate under the assumptions that this λV_{DS} is much smaller than one, so we will ignore this. And calculate g_m based on only this one. And of course, for g_{ds} , we cannot ignore this λ ; if we do, we will get zero, and we will be ignoring a qualitatively significant phenomenon. So, for g_{ds} , we use this. Now, you notice that this part of the expression is nothing, but I_D . So, we say that g_{ds} is approximately λI_D . So, this g_{ds} itself it is proportional to the drain current. And this is the expression that is most often used. We calculate g_{ds} using this expression λI_D . So, I hope this part is clear.

Again this is the expression, but for simplifying the calculations, we ignore this one plus λV_{DS} term, while calculating the operating point current or while calculating the

g_m of the transistor. But we do take into account λ , while calculating g_{ds} , because that is what gives you a non-zero value of λ .

And just to get a feel for numbers, let me assume that λ is point zero five inverse volts. Now, let me first assume that λ equal to zero and calculate everything. And I will use the same transistor as I always been using with a threshold voltage of 1 volt, and a current factor of 100 microamperes per volt square. And I will use an operating point, V_{GS} to be 3 volts. If I do this, I know that if I assume λ equal to 0, I get a drain current of 200 microamperes. You can verify this very easily. And I also get a g_m of 200 micro Siemens. And the drain source conductance will be zero. By the way, let me also assume V_{DS} equal to 3 volt, so that it remains in saturation region. So, this implies saturation, because V_{DS} is more than V_{GS} minus V_T .

Now, if I take this λ value 0.05 volt inverse, what do I get, I get I_D to be whatever I got from the original expression times $1 + \lambda V_{DS}$. And λV_{DS} in this case, is 0.05 volt inverse times 3, so this is 0.15. So, the actual value of I_D turns out to be 230 microamperes. So, there is an error, if we assume 200 microamperes, but that is ok, because if we include this in every expression, we would not be able to calculate anything at all. Similarly, g_m will be the g_m calculated from the original expression, which is 200 micro Siemens times one plus λV_{DS} . These calculations are quite simple, so that is why I am not going through them step by step. So, I assume that you can work out these things quite easily by yourself.

Again, this will turn out to be 200 micro Siemens times this number is 0.15, so this will be 230 micro Siemens. There is an increase in g_m , if you use the complete expression, but usually we ignore that. And finally, g_{ds} itself would be λ times I_D that we originally calculated, which is 200 microamperes. So, λ is point zero five; now 0.05 times 200 microamperes is 10 micro Siemens. So, our model will consist of g_m V_{GS} , and we will continue to use g_m of 200 micro Siemens, ignoring the $1 + \lambda V_{DS}$ term, but significantly we have a resistor here between these two a conductance, the conductance is 10 micro Siemens or whose resistance is 100 kilo ohms. This is the gate, this is the source, and this is the drain. So, the most important effect of this λ is to introduce an incremental conductance between the drain and source of the MOS transistor, and this will directly affect the characteristics of the common source amplifier. What that effect is, we will analyze in the following lessons.